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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Michael Turner; Waikit Fung; Oliver Graudejus; Doug Winandy
Assignee: Novellus Systems, Inc.
Title: Phosphorus-Doped Silicon Dioxide Process To Customize Contact Etch Profiles
Serial No.: 09/998,993 Filing Date: November 15, 2001
Examiner: Unassigned Group Art Unit: Unassigned
Docket No.: M-12396 US

Newport Beach, California
April 9, 2002

BOX MISSING PARTS
COMMISSIONER FOR PATENTS
Washington, D. C. 20231

PETITION FOR EXTENSION OF TIME

Dear Sir:

Applicants respectfully petition for a 2-month extension of time within which to respond to the December 20, 2001 outstanding Office Action, such extension allowing the undersigned until April 20, 2002 to respond.

Please charge the amount of \$400.00 as set forth in the enclosed transmittal letter.

Express Mail Label No.:

EV 004 867 153 US

Respectfully submitted,

Tom Chen
Attorney for Applicant(s)
Reg. No. 42,406

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